	Application No.	Applicant(s)
	10/500,924	BRAUN ET AL.
Notice of Allowability	Examiner	Art Unit
	Kevin D. Williams	2854
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85; NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in t ) or other appropriate commun IGHTS. This application is su	his application. If not included ication will be mailed in due course. <b>THIS</b>
1. A This communication is responsive to the RCE filed 11/20/2	2006 and the supplemental an	nendment filed 12/7/2006
2. ☑ The allowed claim(s) is/are <u>1,9-13,19 and 26</u> .		
3.   Acknowledgment is made of a claim for foreign priority up a)   All b)   Some* c)   None of the:	- ,,,,,	(f).
1. Certified copies of the priority documents have		
2. Certified copies of the priority documents have	* *	
3. Copies of the certified copies of the priority do	cuments have been received i	in this national stage application from the
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		reply complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EXAN es reason(s) why the oath or d	MINER'S AMENDMENT or NOTICE OF lectaration is deficient.
5. CORRECTED DRAWINGS ( as "replacement sheets") mus	st be submitted.	
(a) ☐ including changes required by the Notice of Draftspers		PTO-948) attached
1) ☐ hereto or 2) ☐ to Paper No./Mail Date	,	
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or ir	the Office action of
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t		
<ol> <li>DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT</li> </ol>	sit of BIOLOGICAL MATER FOR THE DEPOSIT OF BIOL	RIAL must be submitted. Note the OGICAL MATERIAL.
		•
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	E   Notice of lafe	mand Datast Application
<ol> <li>Notice of References Ched (P10-892)</li> <li>Dotice of Draftperson's Patent Drawing Review (PT0-948)</li> </ol>	6. ☐ Interview Sun	rmal Patent Application
		ail Date mendment/Comment
<ol> <li>Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date</li> </ol>	7. ∐ Examiner's A	mendment/Comment
<ol> <li>Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ol>	8. 🛛 Examiner's Si	atement of Reasons for Allowance
	9.	

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## Allowable Subject Matter

1. The following is an examiner's statement of reasons for allowance:

The primary reason for the allowance of claim 1 is the limitation of a printing plate surface having at least one area with intaglio structures and at least one area with embossing microstructures, at least one of –

a height or lateral structural size of the embossing microstructures being of an order of magnitude in the range of 5 to 100 microns, and

a height or lateral structural size of the embossing microstructures being of an order of magnitude of less than 1 micron,

where parts of the embossing microstructures closest to the printing plate surface are located 20 microns to 100 microns below the plate surface, in combination with the other claimed language.

The primary reason for the allowance of claim 19 is the limitation of producing intaglio structures and embossing microstructures in an intaglio printing plate, parts of the embossing microstructures closest to the printing plate surface being located 20 microns to 100 microns below the plate surface, and at least one of –

a height or lateral structural size of the embossing microstructures being of an order of magnitude in the range of 5 to 100 microns, and

a height or lateral structural size of the embossing microstructures being of an order of magnitude of less than 1 micron,

in combination with the other claimed language.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kevin D. Williams whose telephone number is (571) 272-2172. The examiner can normally be reached on Monday - Friday, 8:30am - 6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Judy Nguyen can be reached on (571) 272-2258. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

KDW

December 6, 2006

Daniel J. Colilia Primary Examiner Art Unit 2854